

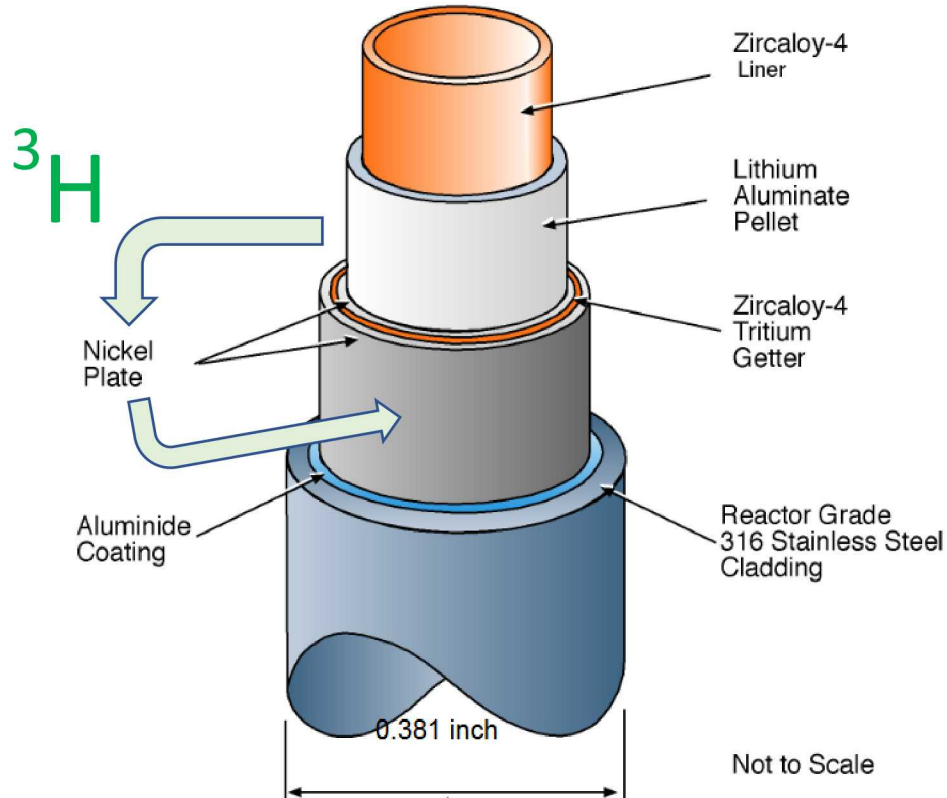
# How oxygen and water affect hydrogen absorption in nickel

This paper describes objective technical results and analysis. Any subjective views or opinions that might be expressed in the paper do not necessarily represent the views of the U.S. Department of Energy or the United States Government.

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*K.A. Burns et al., PNNL-22086, (2012).*

Nickel plating regulates the tritium flow from the pellet to the getter:

- Too fast flow leads to not-uniform growth of hydride in the getter.
- Too slow leads to tritium gas build up in the pellet.

Oxygen & water on the surface of the Ni can influence the flow hydrogen into and out of the Ni.

Our study aims at providing insight into the relevant surface mechanisms.

## Key hypothesis:

Small amounts of surface oxygen (and maybe water) can reduce hydrogen uptake by the nickel surface

## Key challenges:

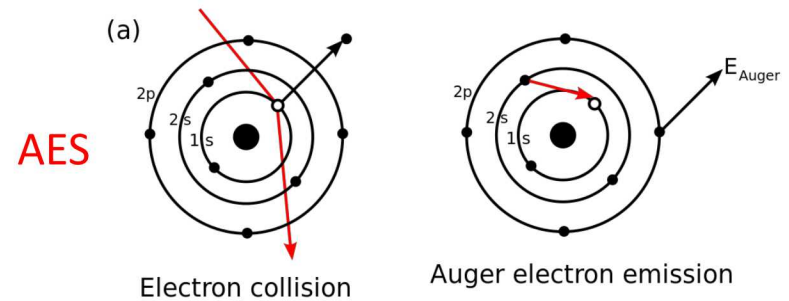
1. Need precisely-controlled nickel surfaces
2. Need techniques sensitive to small amounts of surface hydrogen

Typically, surface techniques are either ...

- “blind” to hydrogen: XPS or AES

or...

- Weak signal, often convoluted with substrate contributions:  
STM, LEED, Helium atom scattering (HAS)



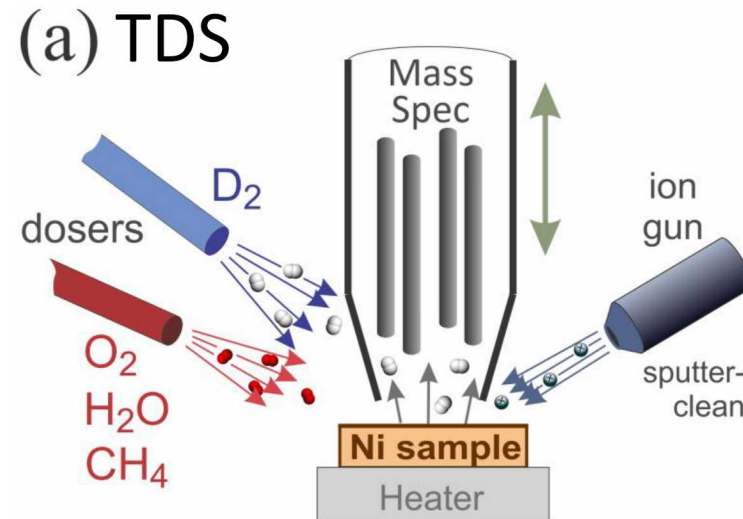
Taken from  
wikipedia.org

# Our approach:

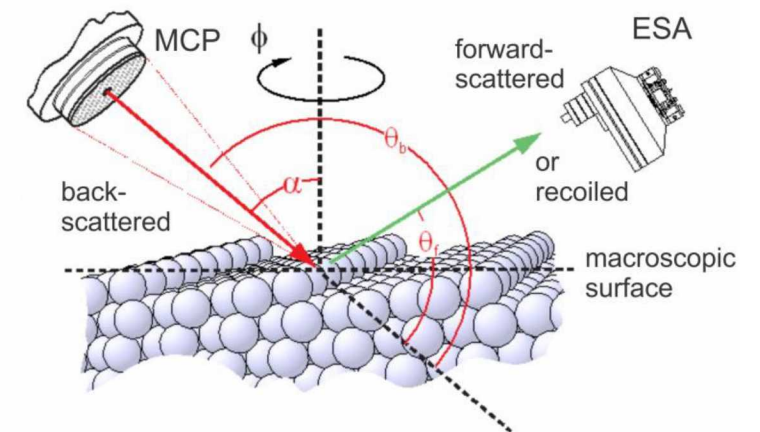
First address this well-defined question:

- How does  $O_2$  on the surface of Ni affect its hydrogen adsorption?
- Work on precisely controlled Ni surfaces.
- Employ two techniques with sub-monolayer sensitivity to hydrogen:

UHV  
Setups:



(b) ARIES





# Thermal Desorption Spectroscopy (TDS)

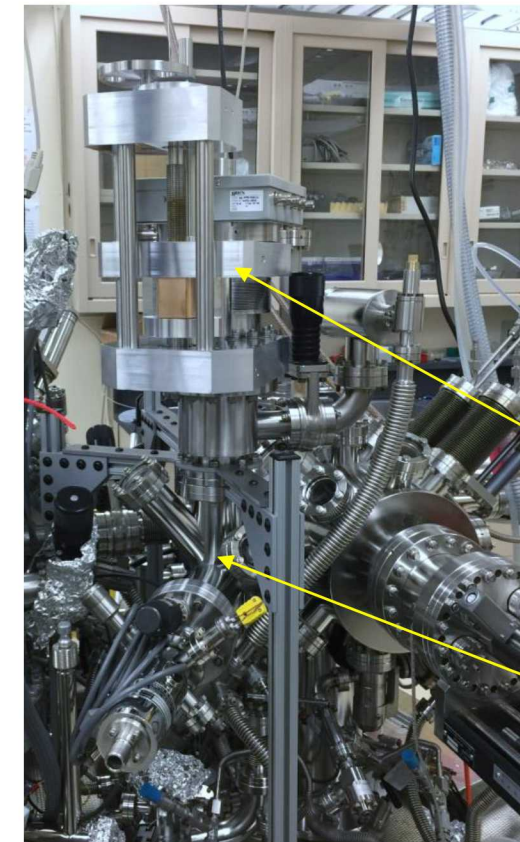
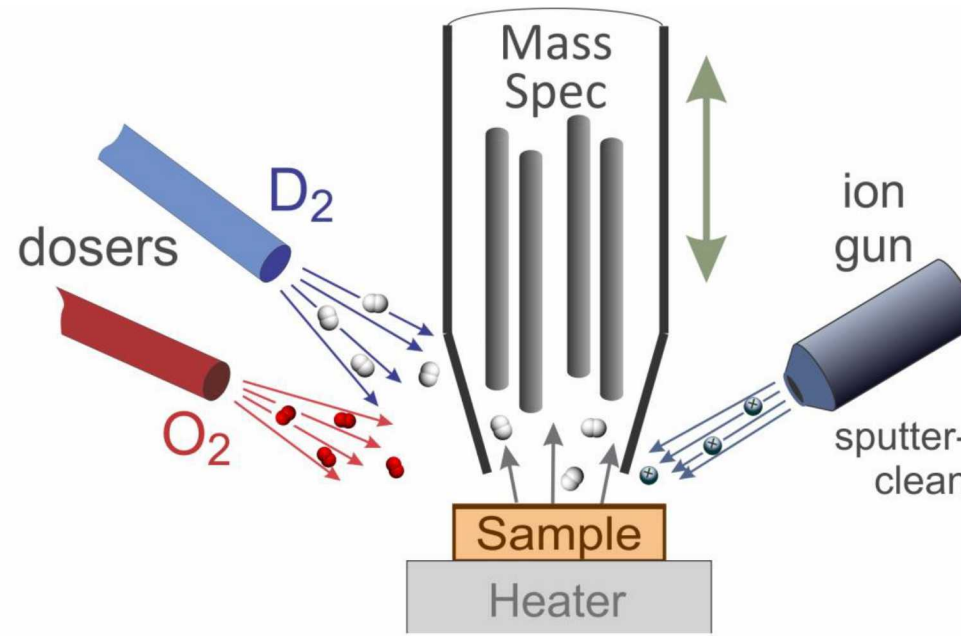
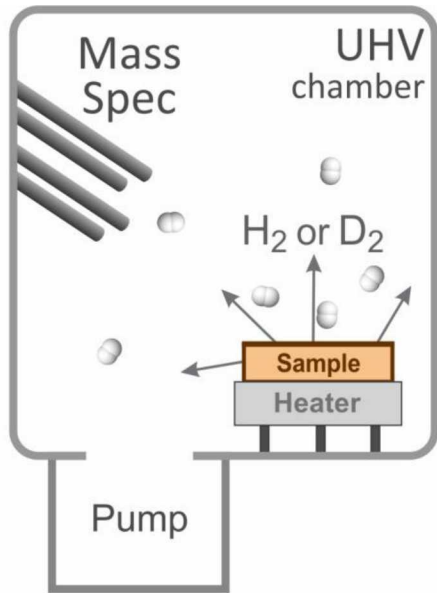
Our new setup:

- Precise control of sample surface
- extremely sensitive measurements of  $H_2$  or  $D_2$  release

*Designed with Josh Whaley*

*Commissioned & tested with Chen Wang*

Conventional setup:



mass spectrometer

TDS module

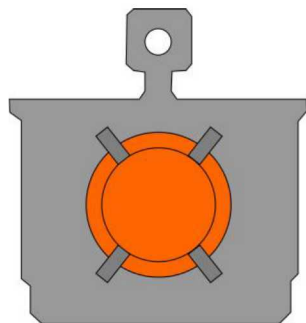
## Upgrades completed within this TPBAR project:

1. **Special exposure chamber** ( $D_2$ ,  $O_2$ ,  $H_2O$ ) dedicated to TDS, which separates gas exposure from TDS module

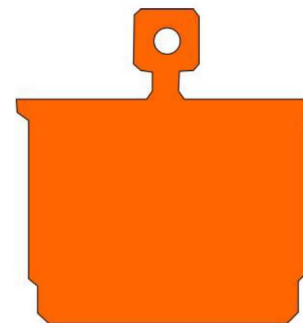
>> eliminates possible desorption contributions from heating stage

2. **Sample holders as samples**

Instead of:



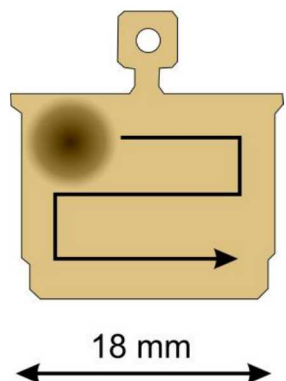
Machine sample holders  
out of sample material,  
i.e., Ni:



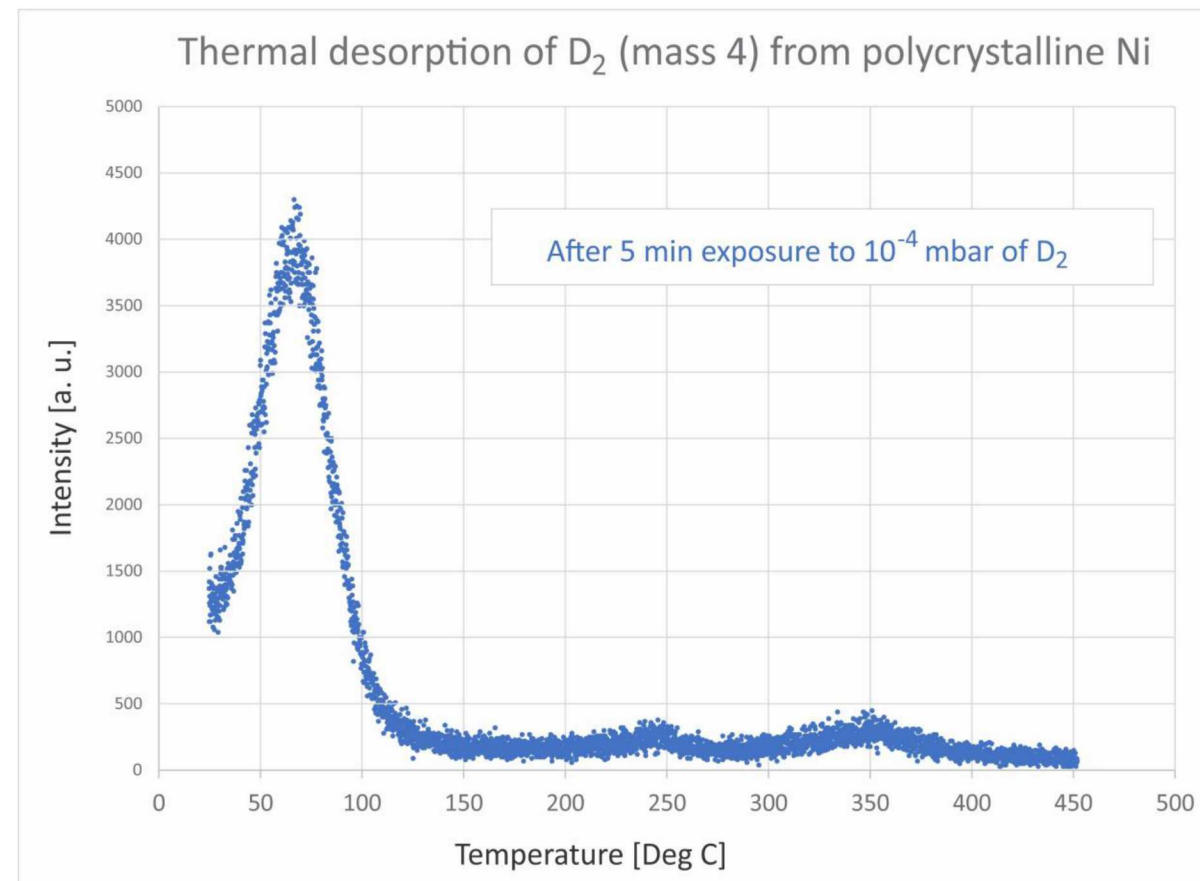
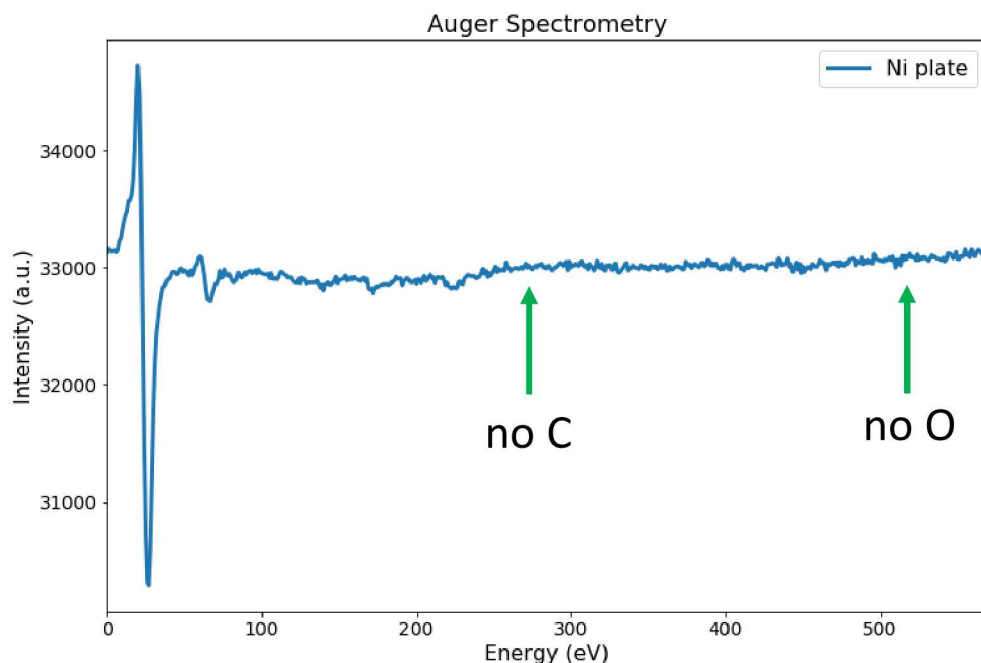
>> nothing but the sample is transferred from deposition chamber into TDS

1. & 2. >>> only the Ni sample is being exposed to the gas environment we want to study, e.g.,  $D_2$ ,  $O_2$ ,  $H_2O$ .

# Thermal desorption Spectroscopy (TDS) of D<sub>2</sub> on Ni



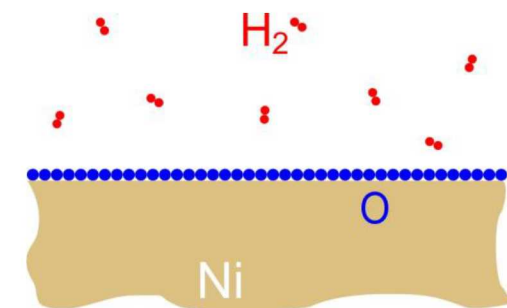
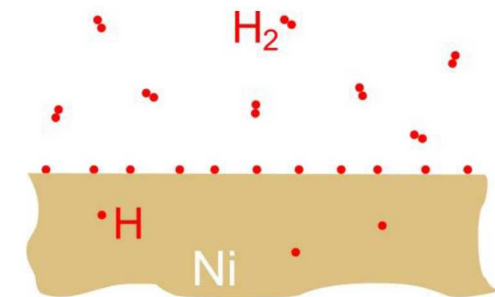
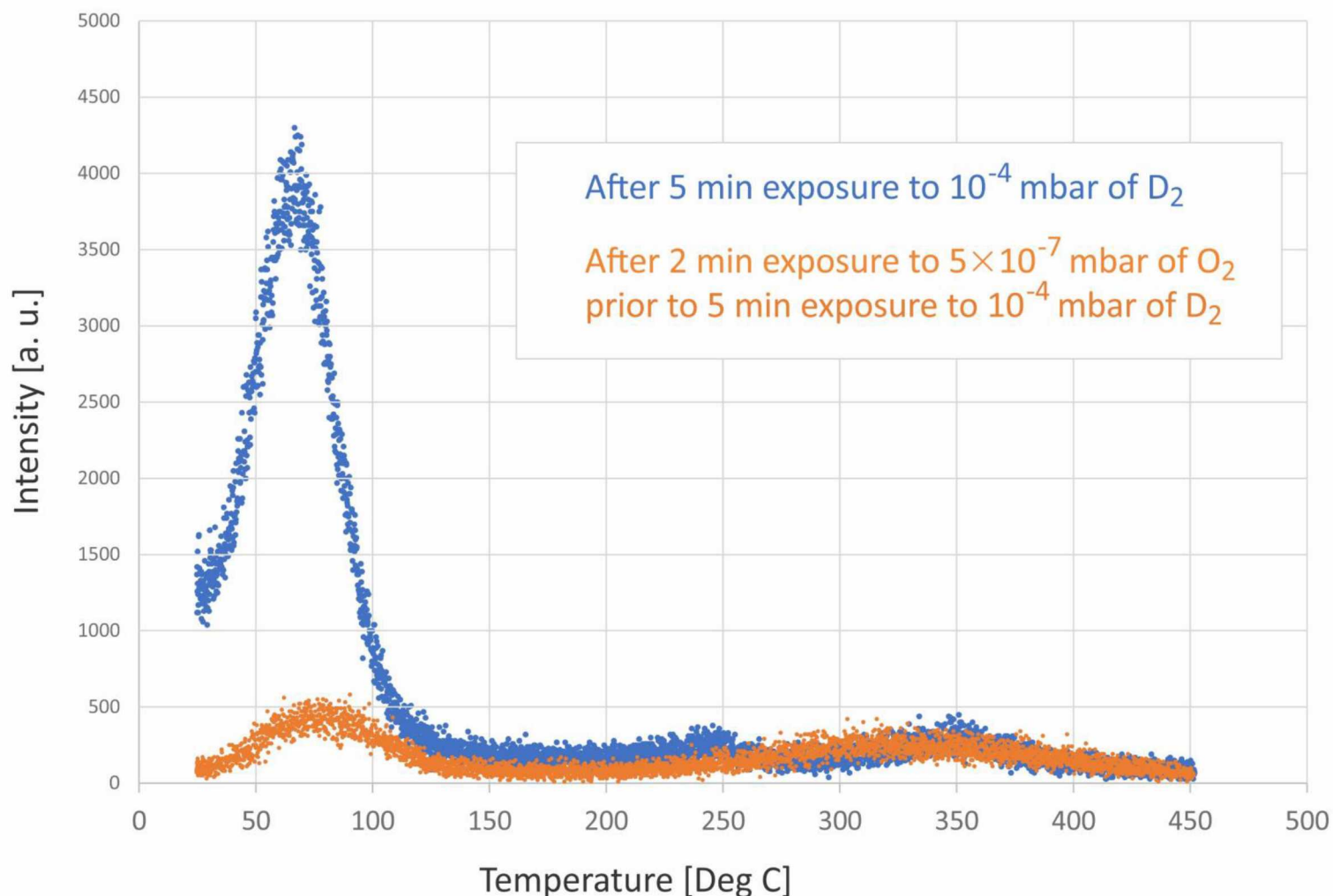
First, extensive Ar<sup>+</sup> ion bombardment to make entire sample plate atomically clean:



Peak at rather low Temp (~70 Deg C) >>>  
We detect monolayer (or less) of D<sub>2</sub> at Ni surface.

# TDS of D<sub>2</sub> on Ni pre-exposed to O<sub>2</sub>

Thermal desorption of D<sub>2</sub> (mass 4) from polycrystalline Ni

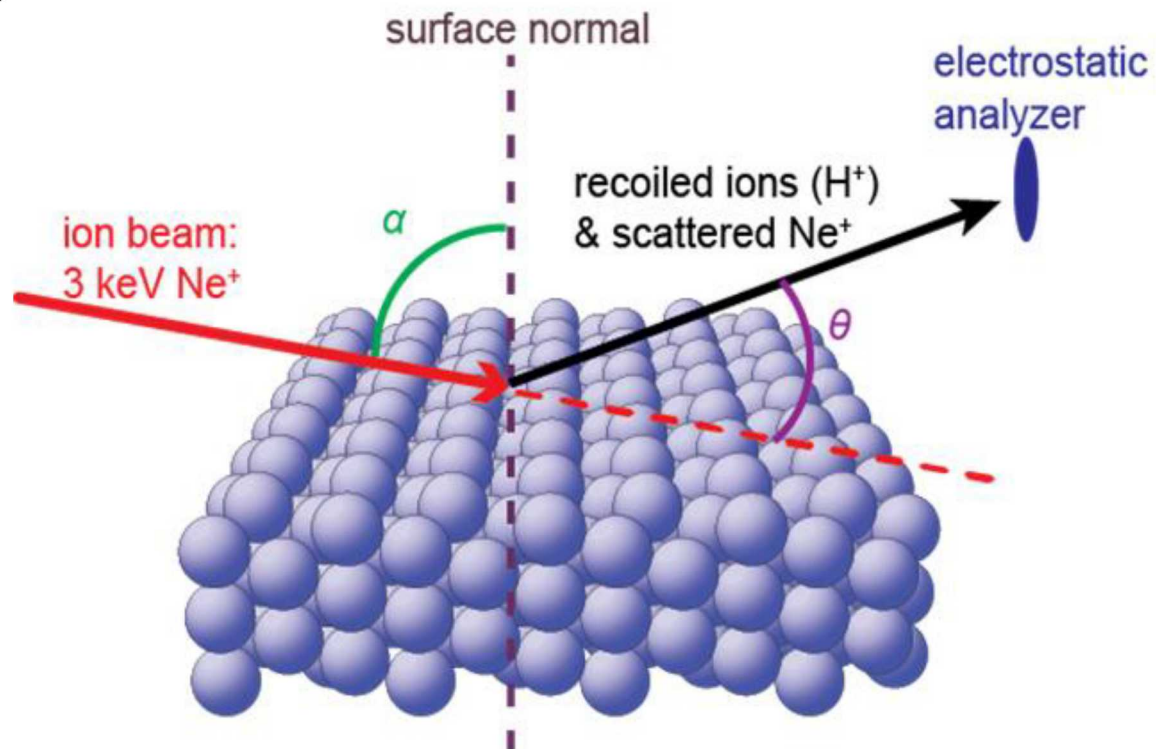


**Small amount of oxygen  
blocks hydrogen adsorption!**

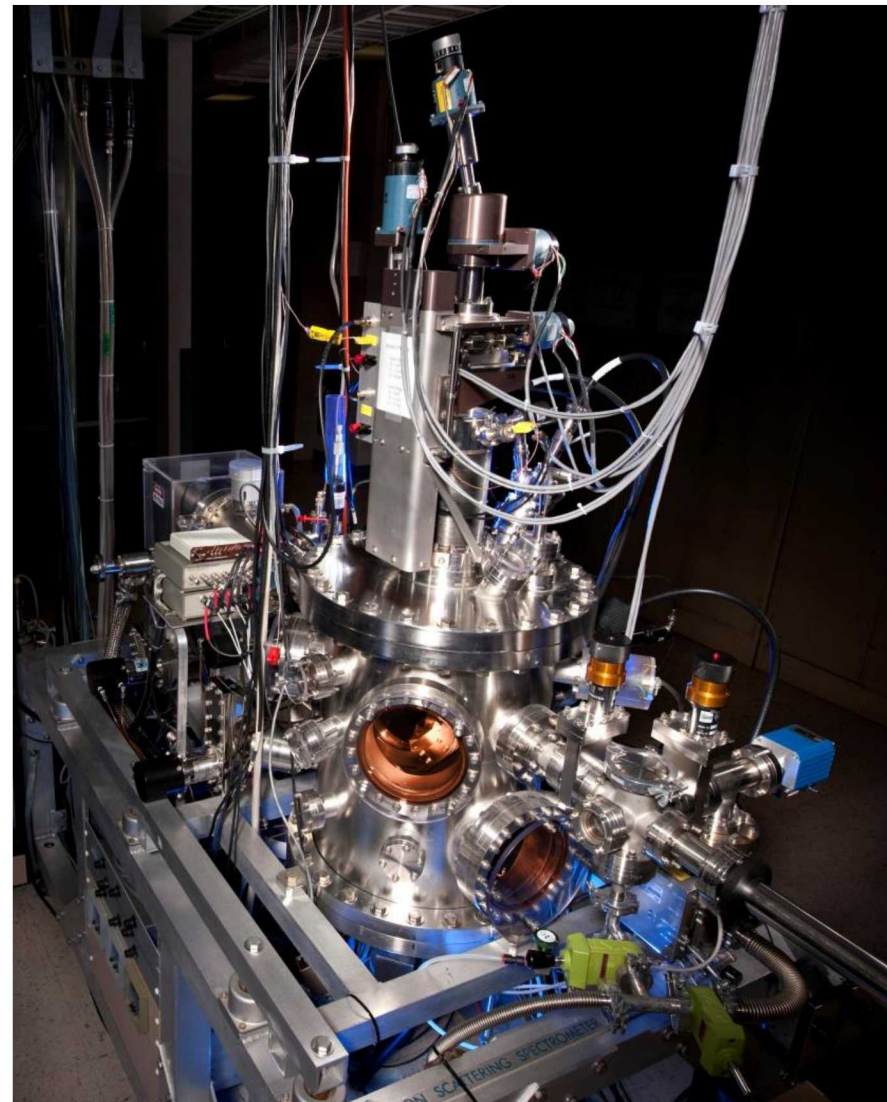
To complete by Dec 31:

- Quantify amount of oxygen needed to block hydrogen
- Same type of study with water





## Angle-resolved ion energy spectroscopy (ARIES)



Low energy ion scattering (LEIS):

Notation: X(QS), Detects projectile ion Ne<sup>+</sup>,  
scattered from the surface atom X

Direct recoil spectroscopy (DRS):

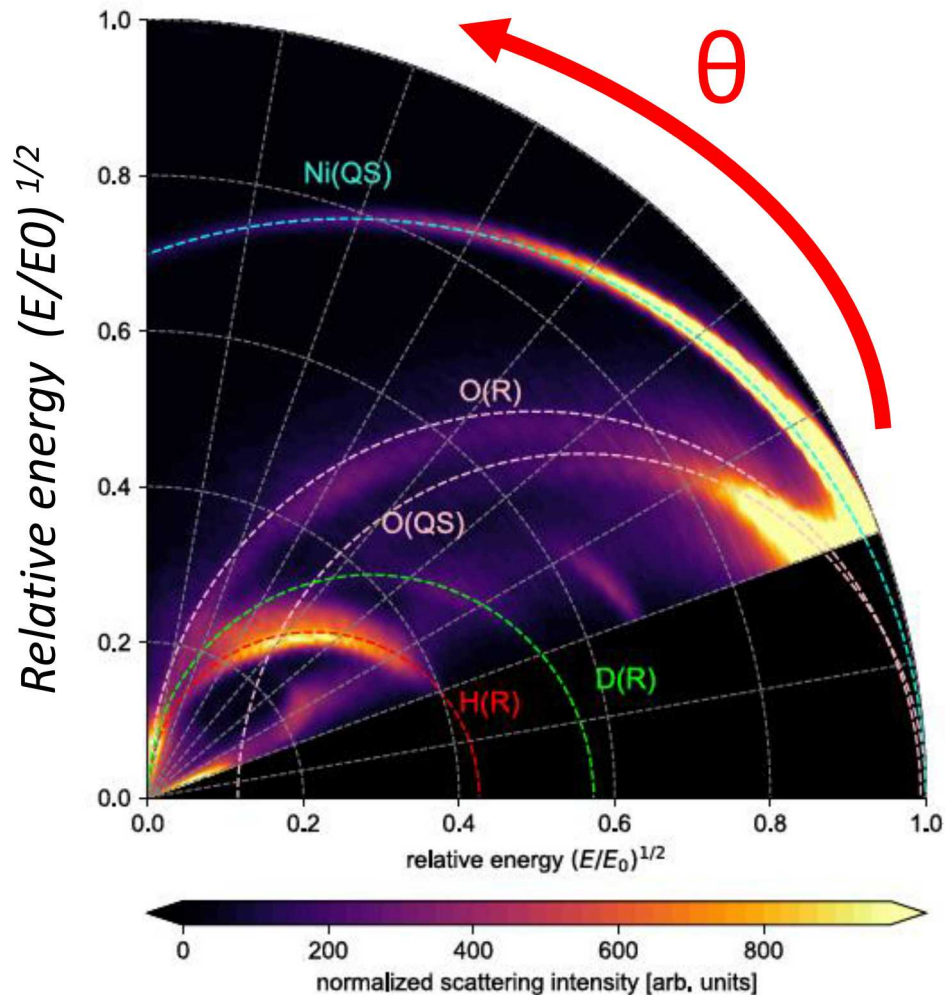
Notation: X(R), Detects surface atom X,  
recoiled by the projectile into the detector.  
like H(R) (recoiled hydrogen)



# Measure clean Ni foil in residual UHV

3 keV Ne<sup>+</sup> beam  $\alpha=80$  Deg from normal

“Collision circle plot” for scattering angles  
 $20^\circ \leq \theta \leq 90^\circ$  ...



... assigns  
circular arcs  
to collision  
processes:

Strongest  
signals from  
H(R), Ni(QS)  
and O(R)

Energies of scattered & recoiled ions,  
assuming elastic collisions,  
conservation of energy & momentum

$$\frac{E_S}{E_0} = \left( \frac{\cos \theta \pm \sqrt{\mu^2 - \sin^2 \theta}}{1 + \mu} \right)^2$$

$$\frac{E_R}{E_0} = \frac{4\mu}{(1 + \mu)^2} \cos^2 \theta$$

$E_S$  = energy of scattered ion

$E_R$  = energy of recoiled ion

$E_0$  = energy of incident ion (3 keV)

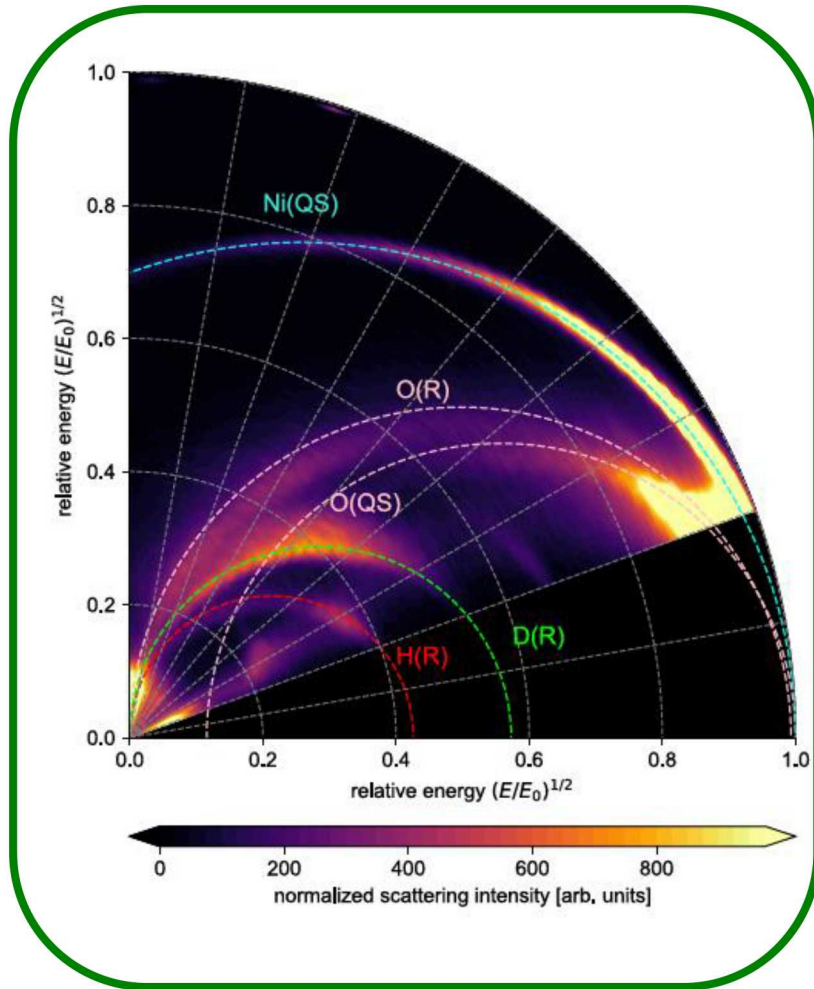
$\vartheta$  = scattering angle

$\mu$  = mass ratio of target atom to incident ion

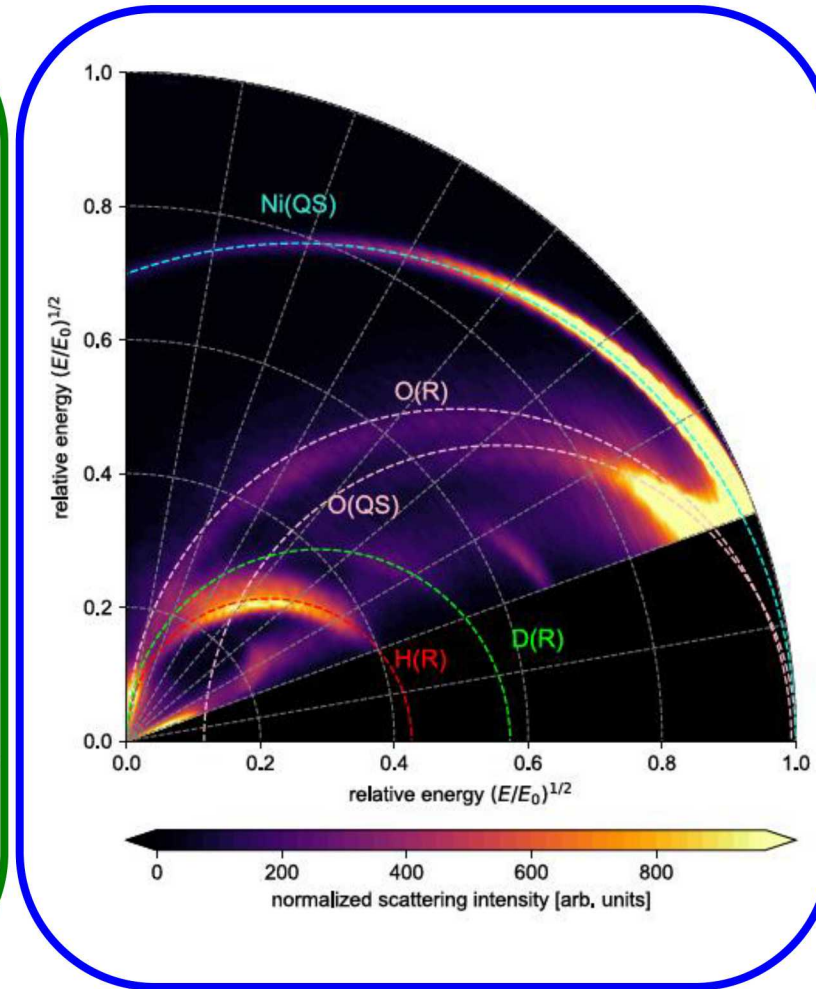
# Collision-circle plots for different gaseous environments...

(Dosing gasses into the chamber via a leak valve)

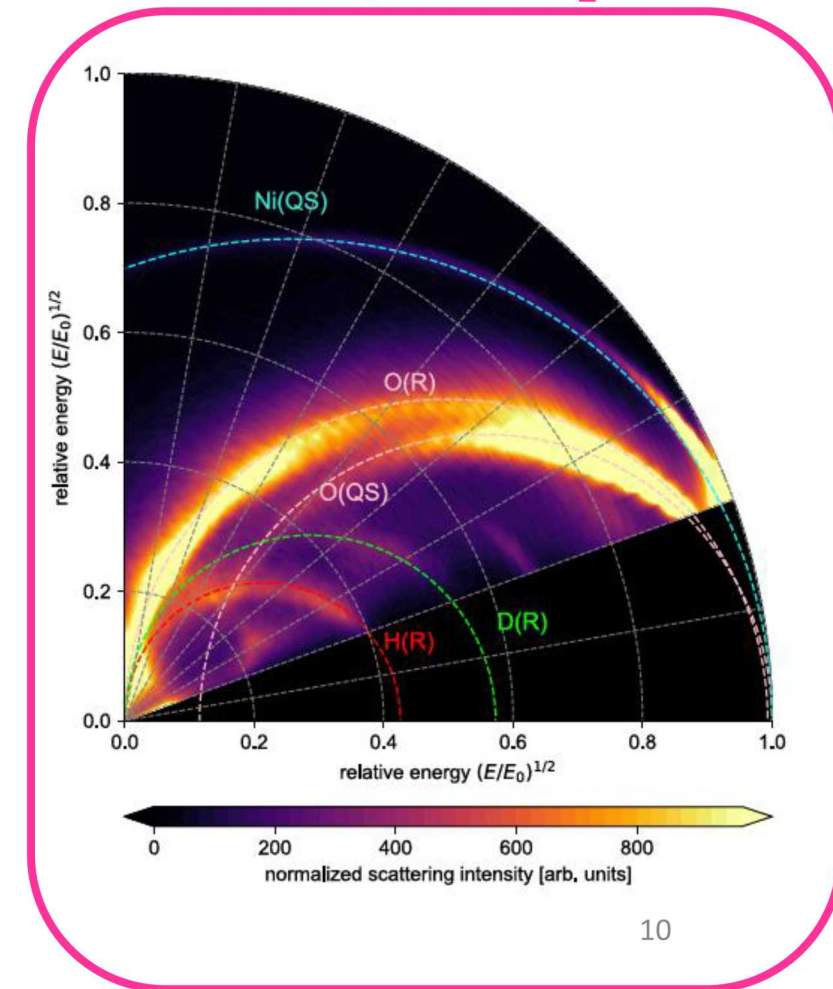
Dosing with  $D_2$



Clean Ni foil



Dosing with  $O_2$



... allow assignment of collision processes relevant during gas exposure.

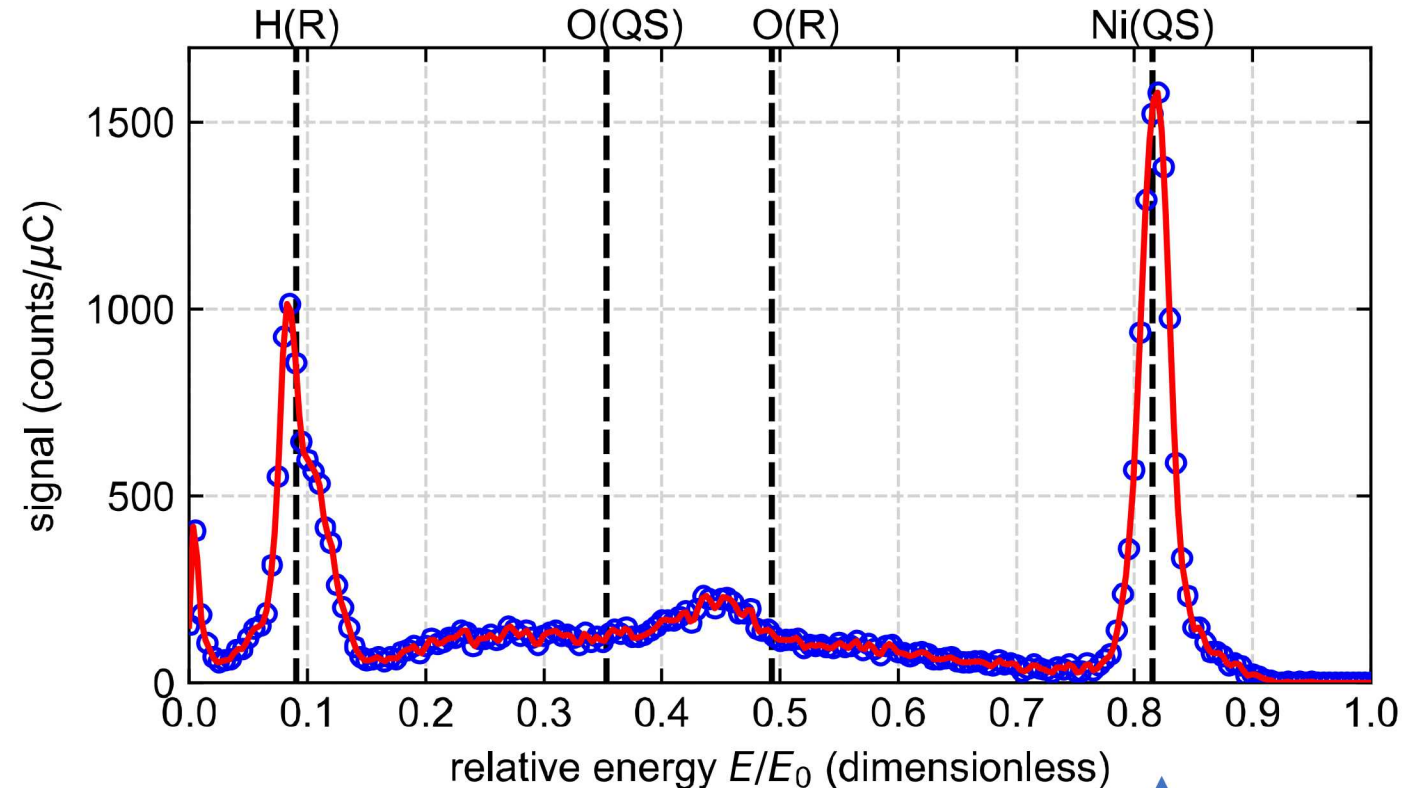
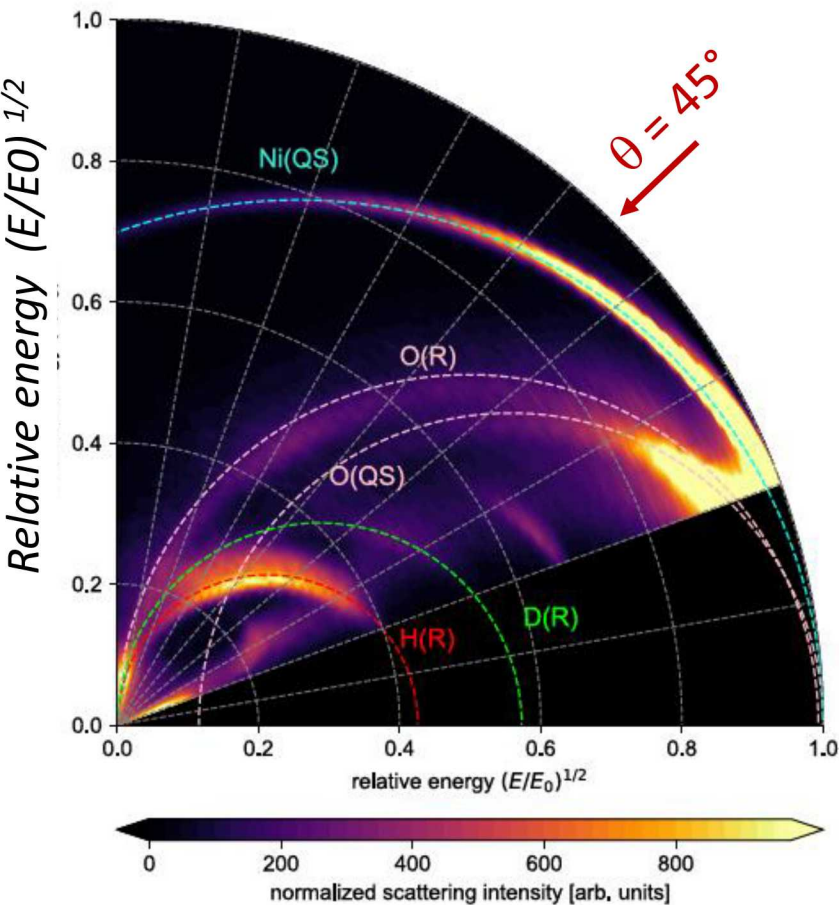


# Baseline ion energy spectrum on Ni foil in “residual UHV”

3 keV Ne<sup>+</sup> beam  $\alpha=80^\circ$  Deg from normal

Fixed scattering angle  $\theta = 45^\circ$

Clean Ni surface



Recoiled H

Trace amounts of impurities  
(mostly O, possibly some C)

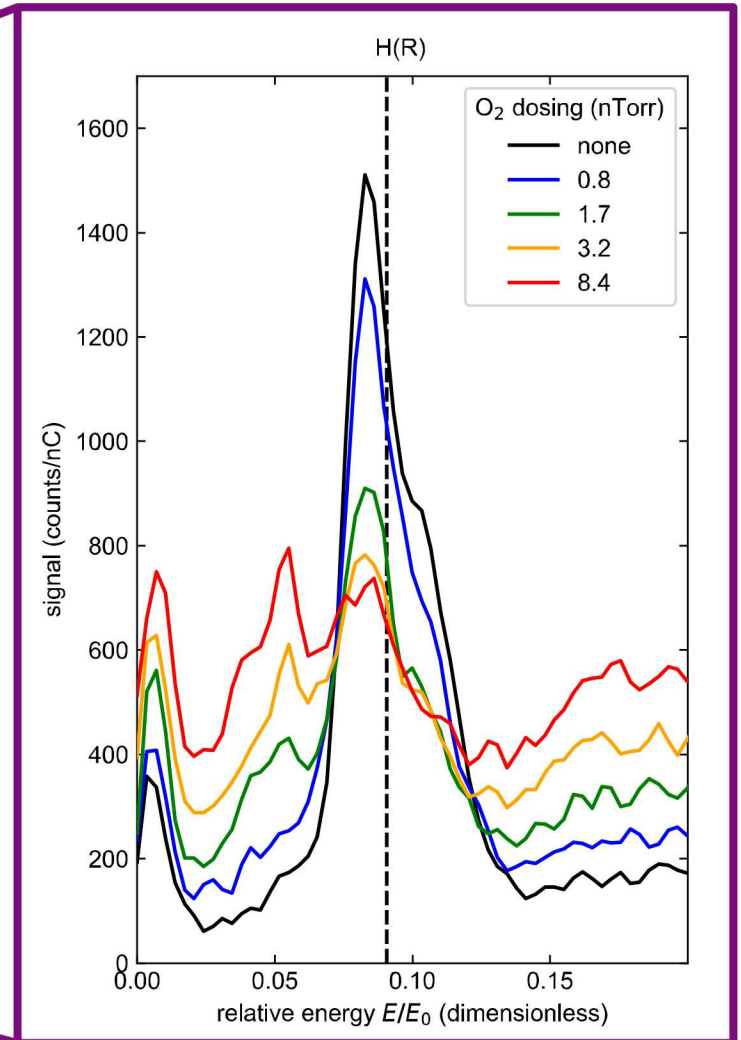
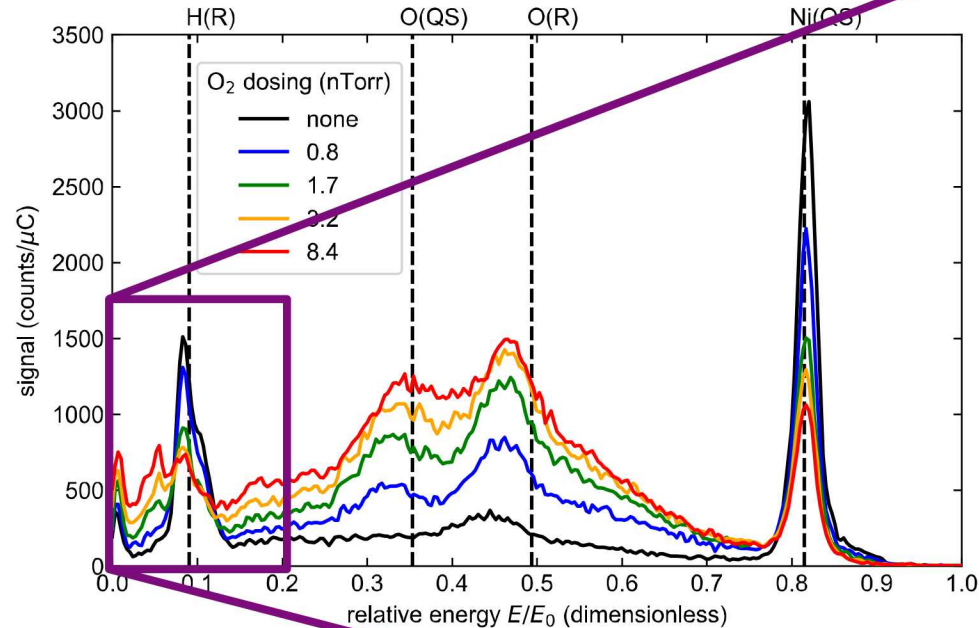
Ne<sup>+</sup>  
scattered  
from Ni



# Effect of oxygen on hydrogen adsorption

3 keV  $\text{Ne}^+$   $\rightarrow$  Ni foil

$\theta = 45^\circ$ ,  $\alpha = 80^\circ$



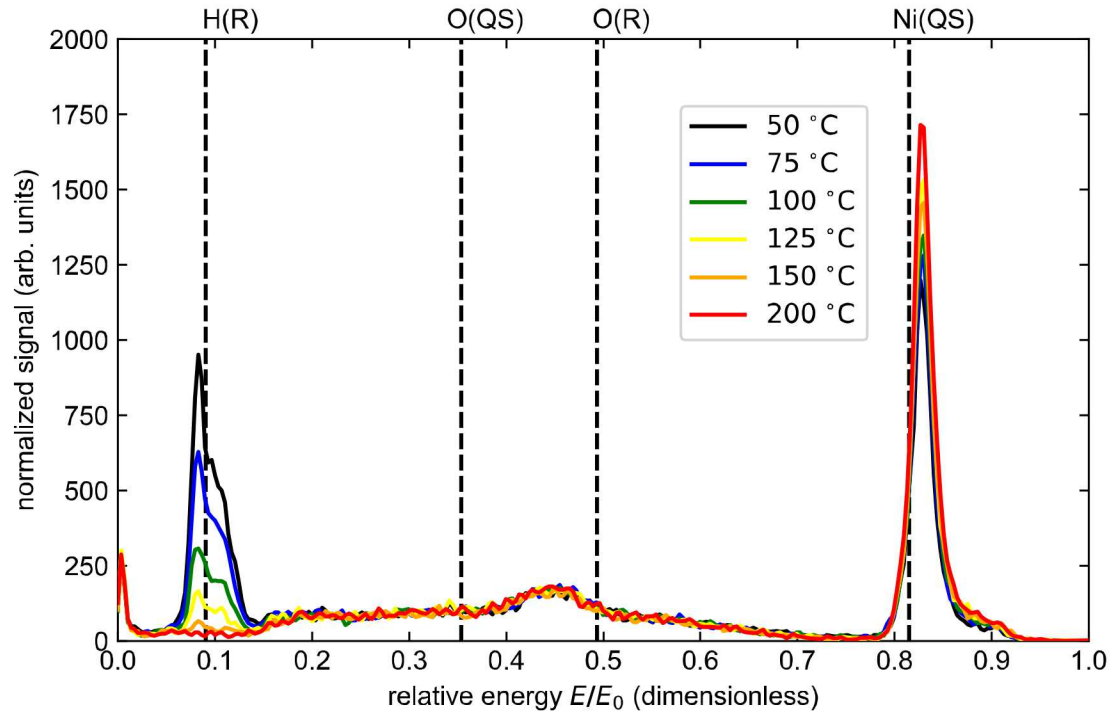
With increasing oxygen dosing:

1. O(QS) & O(R) peaks grow
2. Ni peak diminishes as O coverage increases
3. H peak decreases down to background level

# Temperature effect on H adsorption with & without O<sub>2</sub> dosing



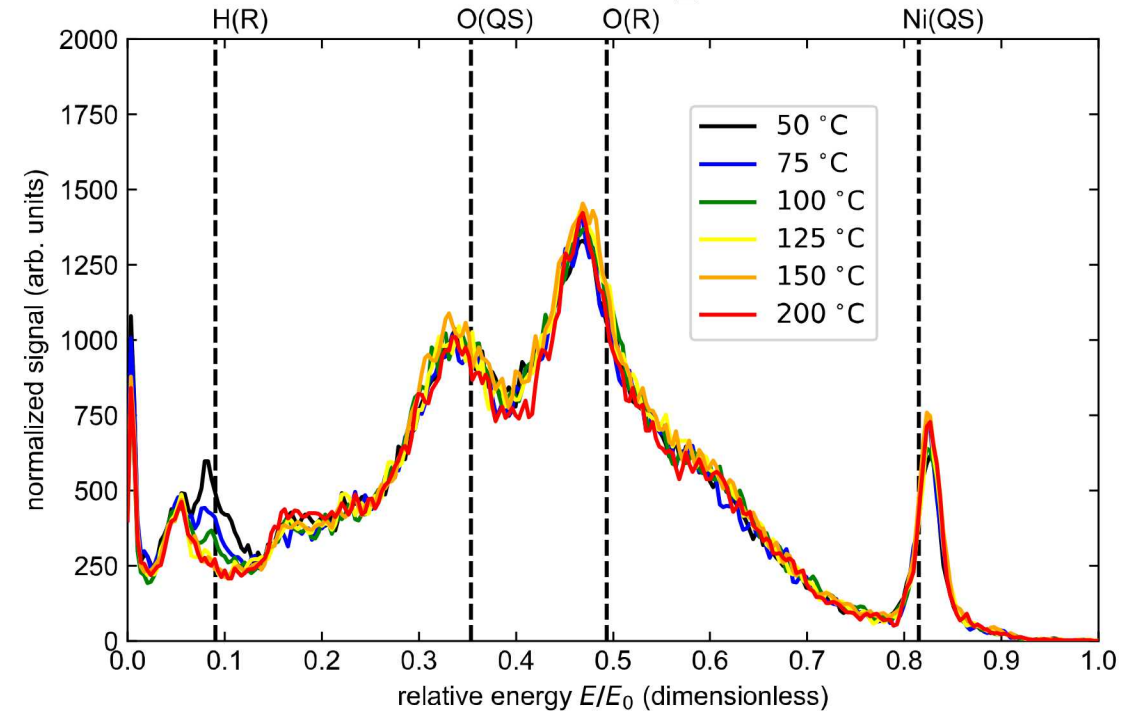
## No O<sub>2</sub> dosing



With increasing temperature:

1. H peak diminishes
2. Ni peak increases (due to less surface H)
3. No changes from 200 °C to 400 °C

## With 2 nTorr O<sub>2</sub> dosing



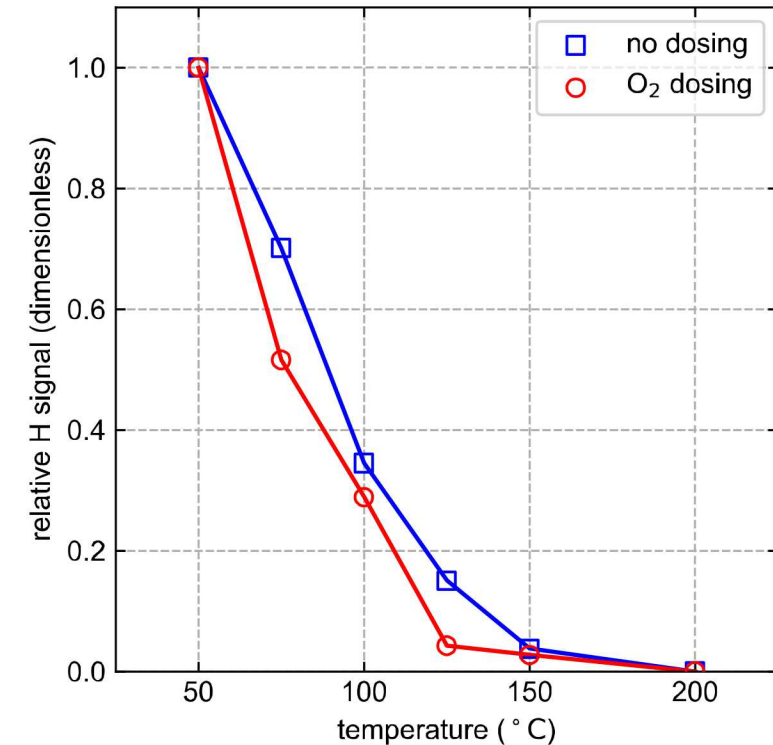
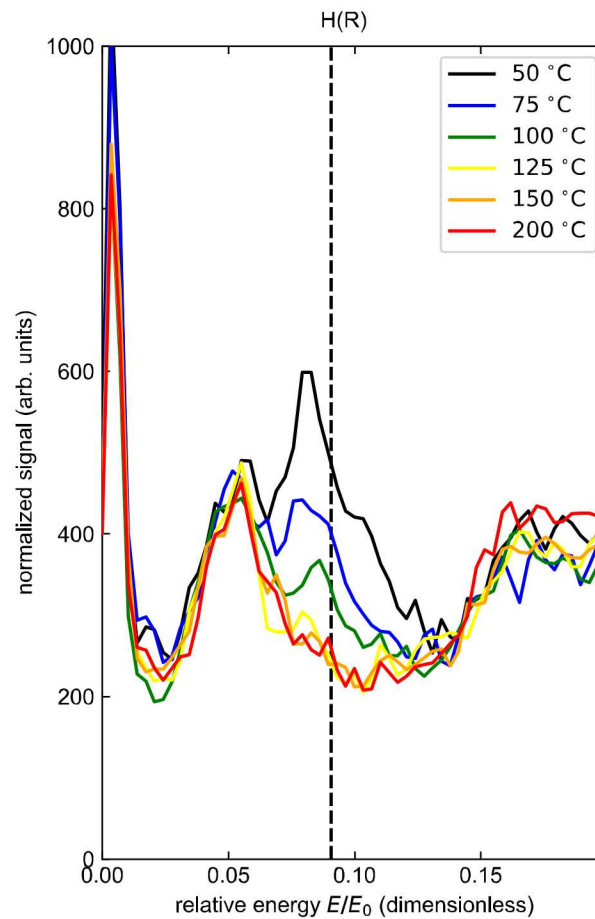
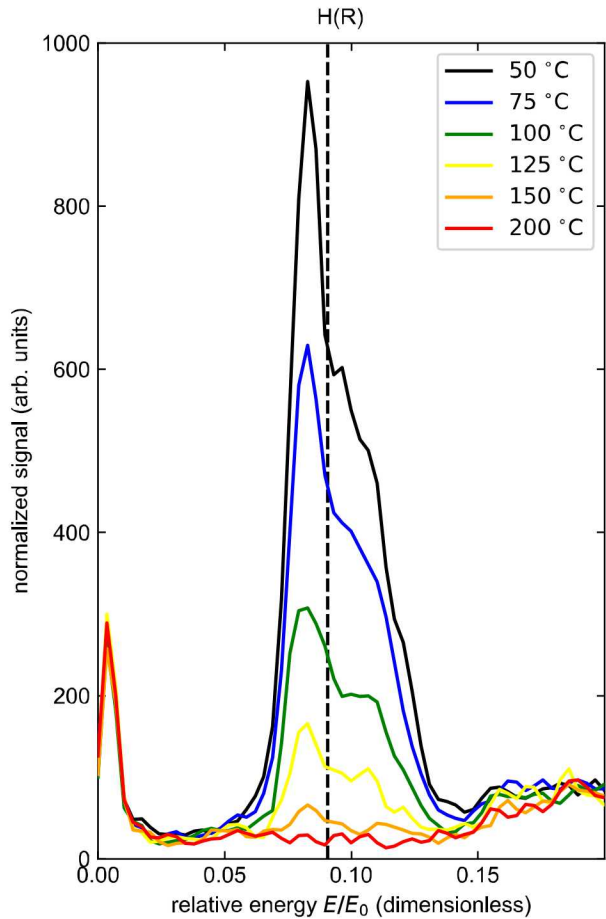
With increasing temperature:

1. H peak diminishes
2. O peaks remains unchanged (up to 400 °C)
3. Ni peak increases slightly

# Temperature effect on H adsorption with & without O<sub>2</sub> dosing (cont.)



Compare H(R) peaks:

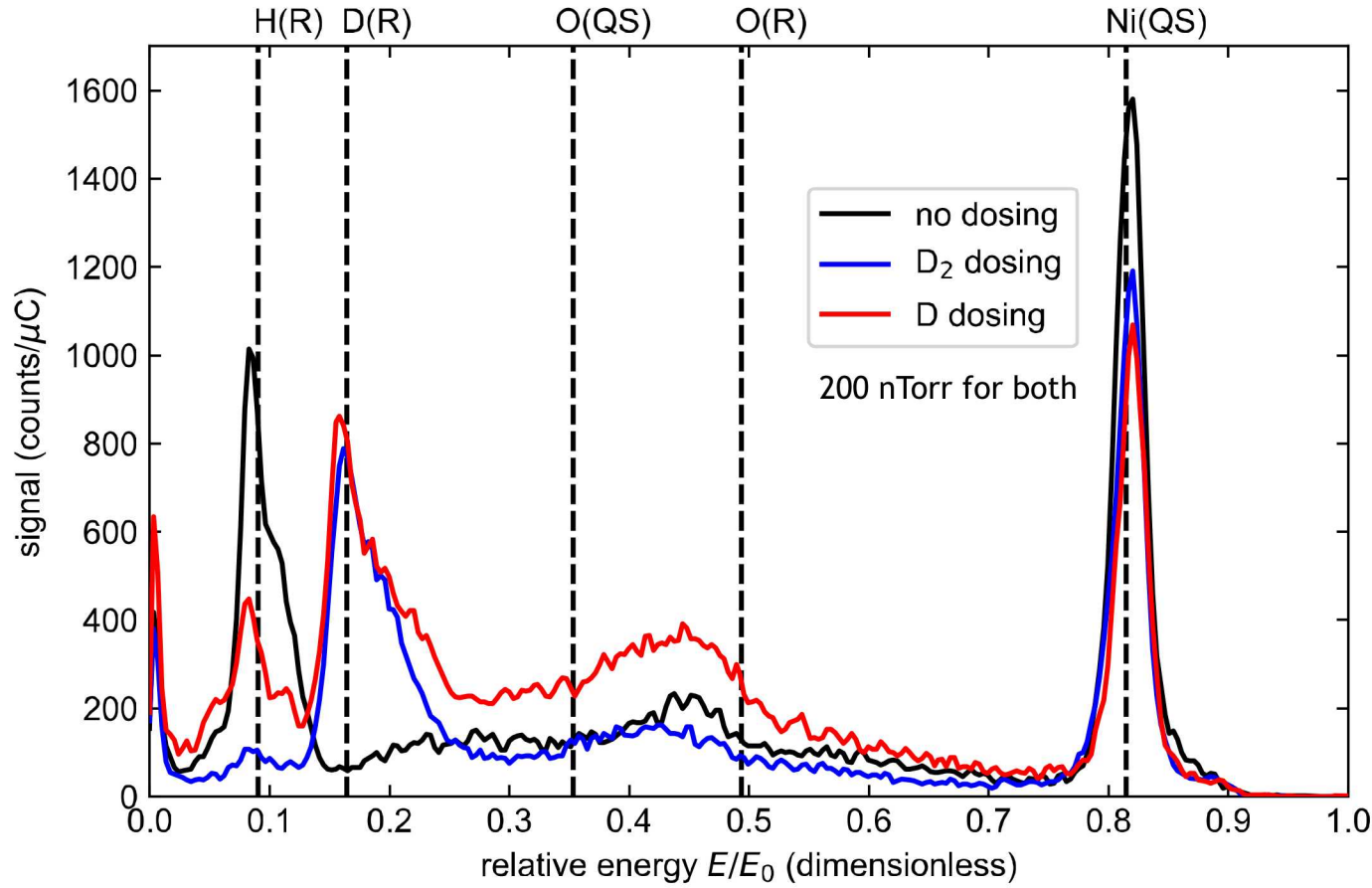


Surface H diminishes more rapidly for increasing temperature with O<sub>2</sub> present

Repulsion by co-adsorbed O ?

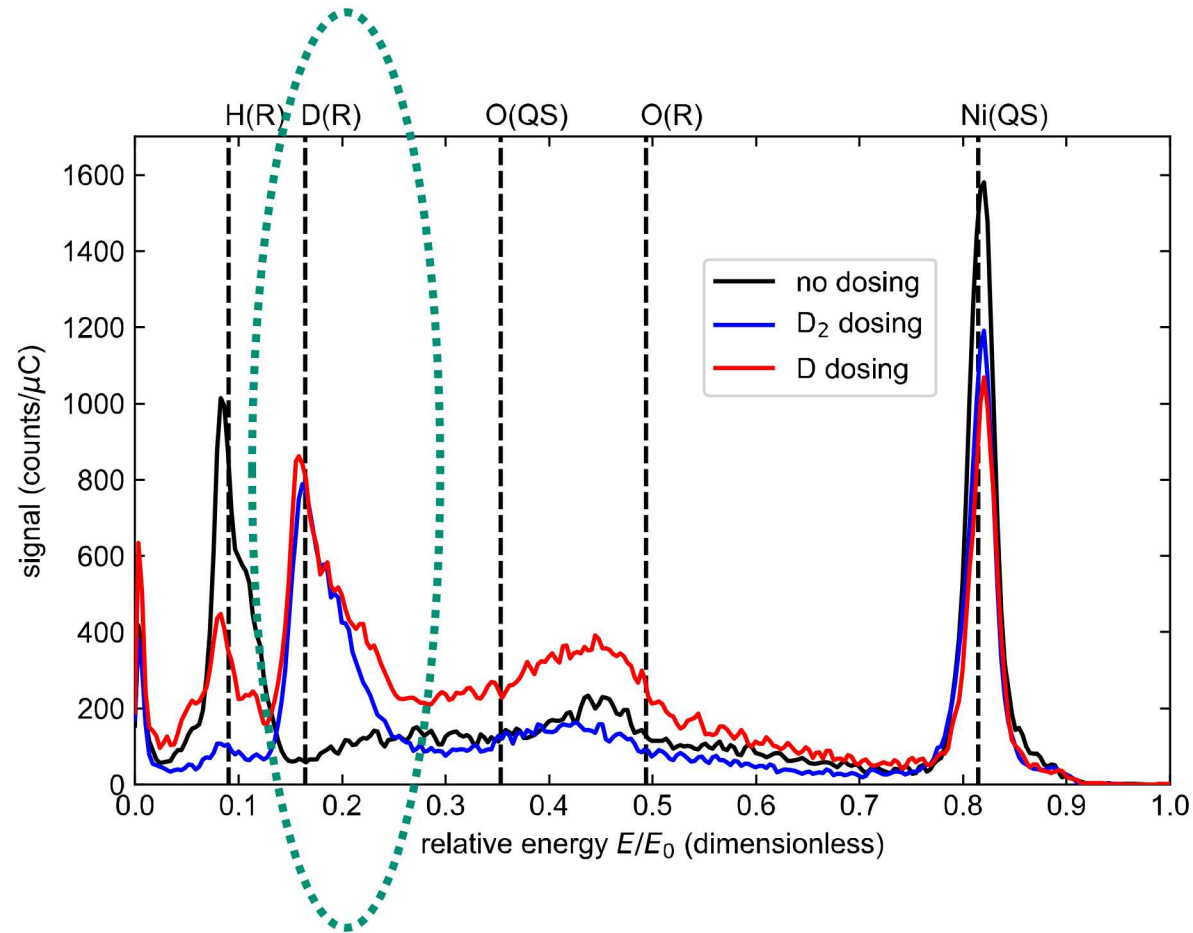


# Examining dissociation: comparison of dosing with $D_2$ vs D

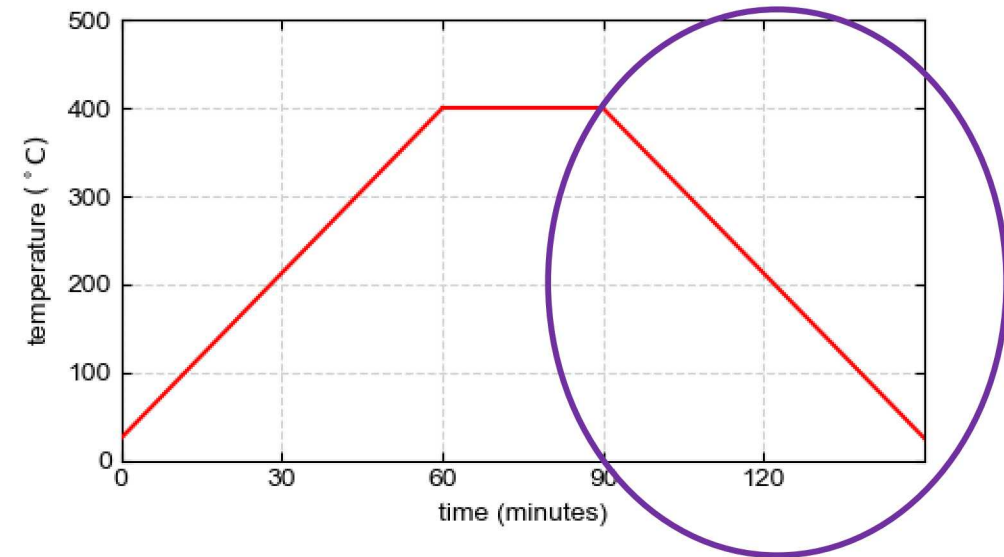


- $D_2$  and D have similar uptake on Ni
- not a significant barrier for  $D_2$  dissociation at the surface
- background for D is larger due to impurities outgassed by H cracker

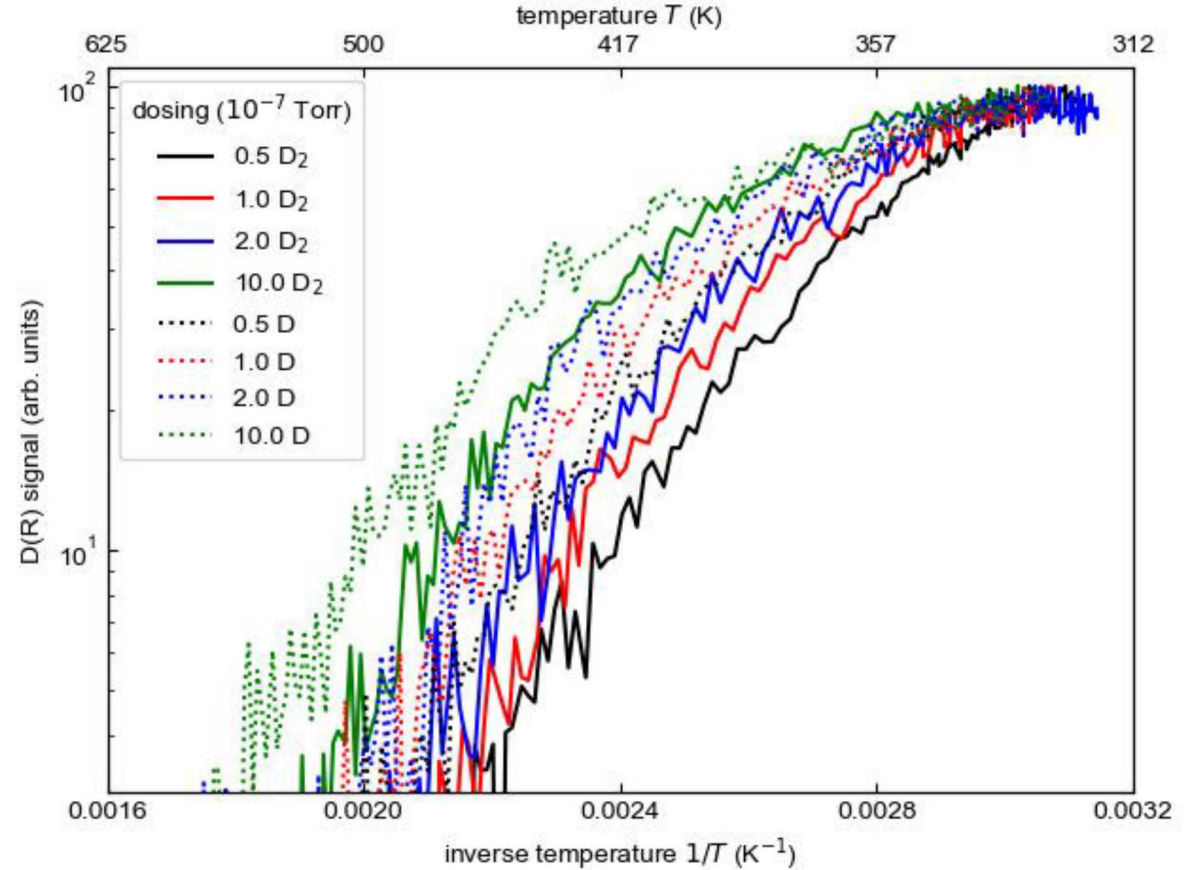
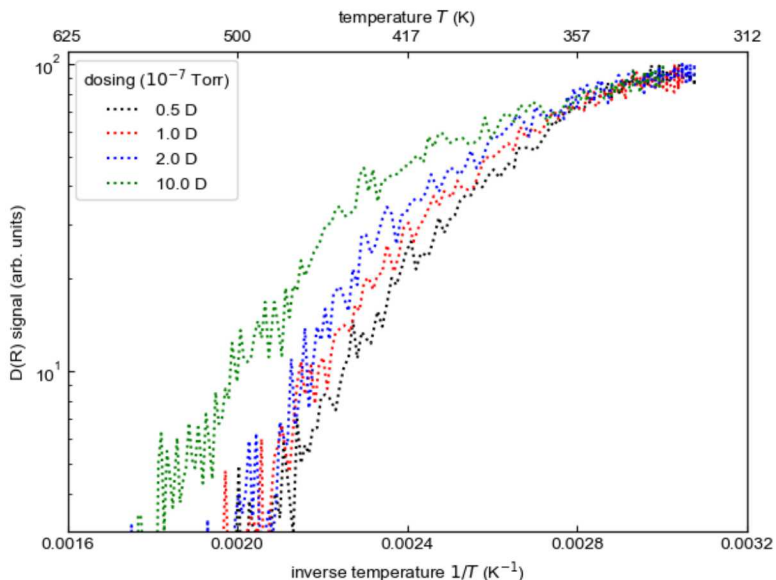
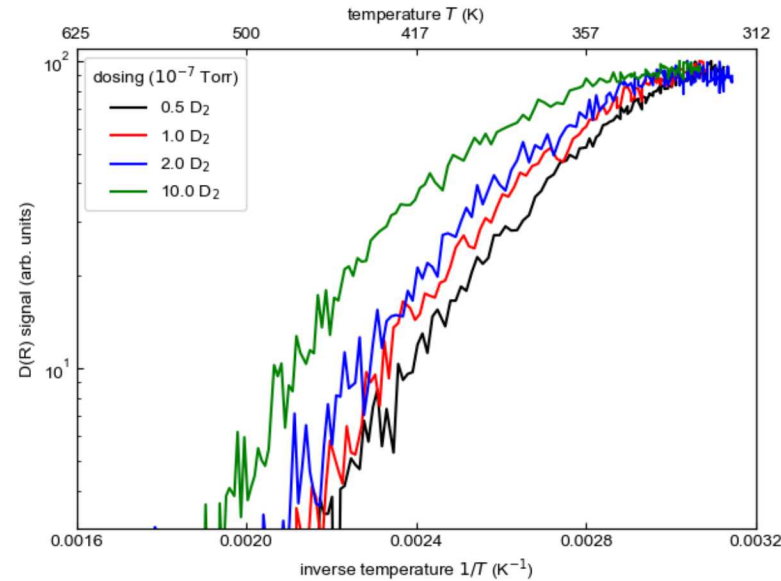
# Temperature effect on hydrogen uptake



isobar measurements of hydrogen uptake by monitoring D(R) while ramping down temperature



# Isobars comparing D and D<sub>2</sub>



For both D and  $D_2$  dosing

- Isobar curves generally obey Arrhenius relation
- Higher pressure  $\rightarrow$  adsorption at higher temperatures

D adsorbs at higher temperature/lower pressure than  $D_2$



## Summary:

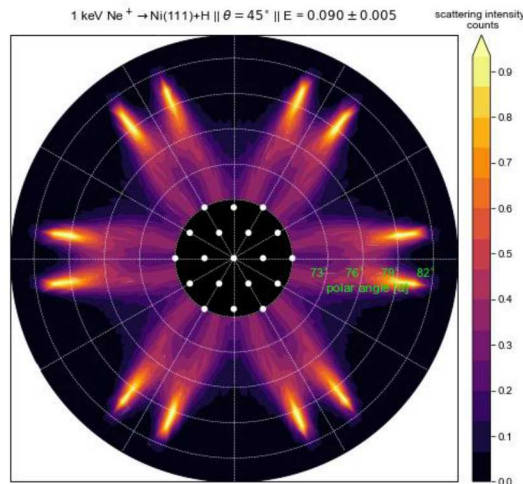
- Demonstrated extreme H-sensitivity of TDS and ARIES
- **Both techniques showed that minute amounts of oxygen can block H-uptake by the Ni surface**
- ARIES: Quantified effect of Temp and dissociation on H-uptake

## Outlook:

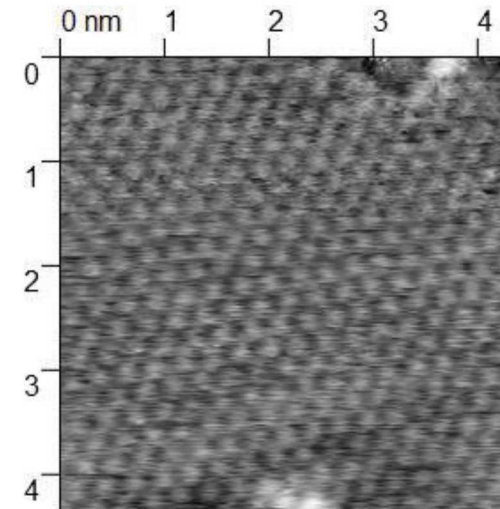
- Include other contaminants ( $\text{H}_2\text{O}$ ,  $\text{CH}_4$ )
- H & O adsorption on Ni single crystals

Combine ARIES  
with modeling

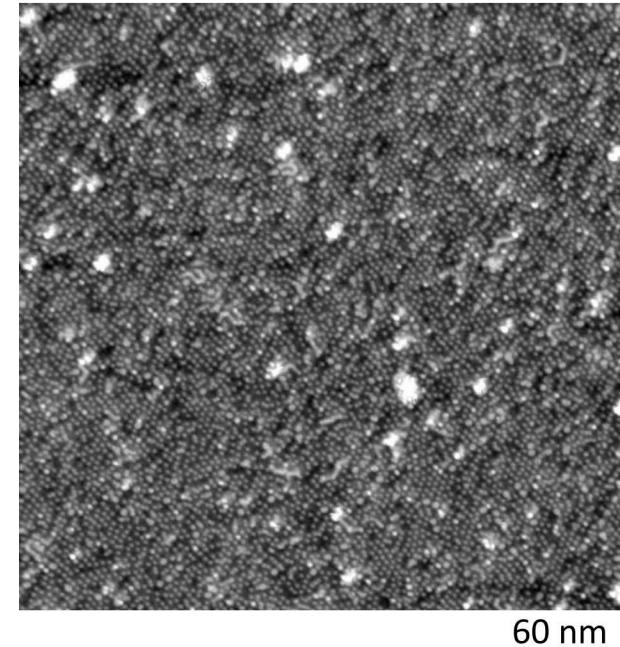
simulated H/Ni(111)  
map for three-fold  
adsorption site



Leverage  
our new  
capability  
to image  
hydrogen  
with STM:



H/Pd (3x3)  
Individual  
H vacancies



H/Pd (1x1)  
Individual H atoms